Functional Oxide Based Thin-Film Materials

Guest Editor:

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Message from the Guest Editor

We invite investigators to submit papers which discuss the development of functional oxide-based thin-film materials, including thin film, nanostructured, and multilayered forms. Mixing oxide-based alloys with other materials could allow for the possible fabrication of advanced devices. Furthermore, the diluted magnetic crystals and combination with two-dimensional materials are welcomed.
Message from the Editor-in-Chief

Crystals are a very important class of structured material, both from a scientific and technological viewpoint. In 2011, the Nobel Prize in Chemistry was awarded to Dan Schechtman for his work on quasicrystals. Our journal already expresses in its name *Crystals* that its focus centers around all aspects of this class of materials, which has fascinated humankind from its beginning. Despite decades of research on crystals, it remains a hot and fascinating research topic.

*Crystals* is a good platform for dissemination of knowledge in this area.

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